

CPMF-1200-S160B

Z-FET™ Silicon Carbide MOSFET

N-Channel Enhancement Mode
Bare Die

V_{DS}	= 1200 V
$R_{DS(on)}$	= 160 mΩ
Q_g	= 47 nC

Features

- Industry Leading $R_{DS(on)}$
- High Speed Switching
- Low Capacitances
- Easy to Parallel
- Simple to Drive

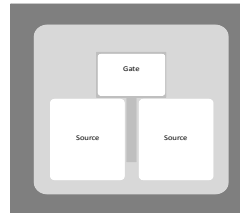
Benefits

- Higher System Efficiency
- Reduced Cooling Requirements
- Avalanche Ruggedness
- Increase System Switching Frequency

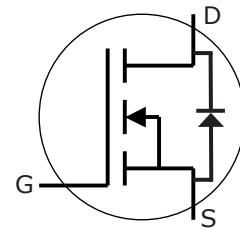
Applications

- Solar Inverters
- Motor Drives
- Military and Aerospace

Package



DIE



Part Number	Package
CPMF-1200-S160B	DIE

Maximum Ratings

Symbol	Parameter	Value	Unit	Test Conditions	Note
I_D	Continuous Drain Current	26.1	A	$V_{GS}@20V, T_C = 25^\circ C$	1
		14.7		$V_{GS}@20V, T_C = 100^\circ C$	
I_{Dpulse}	Pulsed Drain Current	56	A	Pulse width t_p limited by T_{jmax} $T_C = 25^\circ C, t_p = 1ms$	1
E_{AS}	Single Pulse Avalanche Energy	1.1	J	$I_D = 10A, V_{DD} = 50 V,$ $L = 9.5 mH$	
E_{AR}	Repetitive Avalanche Energy	400	mJ	t_{AR} limited by T_{jmax}	
I_{AR}	Repetitive Avalanche Current	10	A	$I_D = 10A, V_{DD} = 50 V, L = 3 mH$ t_{AR} limited by T_{jmax}	
V_{GS}	Gate Source Voltage	-5/+25	V		
P_{tot}	Power Dissipation	177.4	W	$T_C = 25^\circ C$	1
T_J, T_{stg}	Operating Junction and Storage Temperature	-55 to +135	$^\circ C$		
T_L	Solder Temperature	260	$^\circ C$	1.6mm (0.063") from case for 10s	

Note:

1. Assumes a thermal resistance junction to case of $\leq 0.62^\circ C/W$.

Electrical Characteristics

Symbol	Parameter	Min.	Typ.	Max.	Unit	Test Conditions	Note
$V_{(BR)DSS}$	Drain-Source Breakdown Voltage	1200			V	$V_{GS} = 0V, I_D = 100\mu A$	
$V_{GS(th)}$	Gate Threshold Voltage	2.1	2.5	4	V	$V_{DS} = V_{GS}, I_D = 1mA, T_J = 25^\circ C$	2
			1.8			$V_{DS} = V_{GS}, I_D = 1mA, T_J = 135^\circ C$	
I_{DSS}	Zero Gate Voltage Drain Current		0.5	50	μA	$V_{DS} = 1200V, V_{GS} = 0V, T_J = 25^\circ C$	
			5	125		$V_{DS} = 1200V, V_{GS} = 0V, T_J = 135^\circ C$	
I_{GSS}	Gate-Source Leakage Current			250	nA	$V_{GS} = 20V, V_{DS} = 0V$	
$R_{DS(on)}$	Drain-Source On-State Resistance		160	220	m Ω	$V_{GS} = 20V, I_D = 10A, T_J = 25^\circ C$	
			190	260		$V_{GS} = 20V, I_D = 10A, T_J = 135^\circ C$	
g_{fs}	Transconductance		3.7		S	$V_{DS} = 20V, I_{DS} = 10A, T_J = 25^\circ C$	fig. 3
			3.4			$V_{DS} = 20V, I_{DS} = 10A, T_J = 135^\circ C$	
C_{iss}	Input Capacitance		928		pF	$V_{GS} = 0V$	fig. 5
C_{oss}	Output Capacitance		63			$V_{DS} = 800V$	
C_{rss}	Reverse Transfer Capacitance		7.45			$f = 1MHz$ $V_{AC} = 25mV$	
$t_{d(on)i}$	Turn-On Delay Time		7		ns	$V_{DD} = 800V$ $V_{GS} = -2/20V$ $I_D = 10A$ $R_G = 6.8\Omega$ $L = 856\mu H$ Per JEDEC24 Page 27	fig. 11
t_r	Rise Time		14				
$t_{d(off)i}$	Turn-Off Delay Time		46				
t_{fi}	Fall Time		37				
E_{ON}	Turn-On Switching Loss		261		μJ		
E_{Off}	Turn-Off Switching Loss		120		μJ		
R_G	Internal Gate Resistance		13.6		Ω	$V_{GS} = 0V, f = 1MHz, V_{AC} = 25mV$	

Note: 2. The recommended on-state V_{GS} is +20V and the recommended off-state V_{GS} is between -2V and -5V

Reverse Diode Characteristics

Symbol	Parameter	Typ.	Max.	Unit	Test Conditions	Note
V_{sd}	Diode Forward Voltage	3.5		V	$V_{GS} = -5V, I_F = 5A, T_J = 25^\circ C$	
		3.1			$V_{GS} = -2V, I_F = 5A, T_J = 25^\circ C$	
t_{rr}	Reverse Recovery Time	138		ns	$V_{GS} = -5V, I_F = 10A, T_J = 25^\circ C$ $V_R = 800V$ $di/dt = 100A/\mu s$	fig. 12,13
Q_{rr}	Reverse Recovery Charge	94		nC		
I_{rrm}	Peak Reverse Recovery Current	1.57		A		

Gate Charge Characteristics

Symbol	Parameter	Typ.	Max.	Unit	Test Conditions	Note
Q_{gs}	Gate to Source Charge	11.8		nC	$V_{DD} = 800V$ $I_D = 10A$ $V_{GS} = -2/20V$ Per JEDEC24-2	fig.8
Q_{gd}	Gate to Drain Charge	21.5				
Q_g	Gate Charge Total	47.1				

Typical Performance

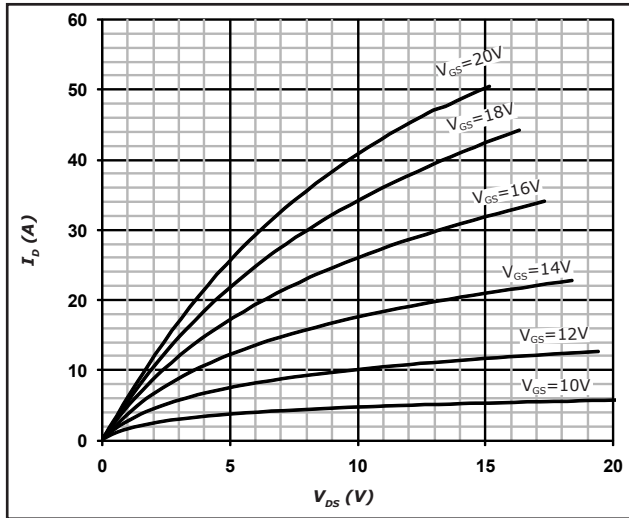


Fig 1. Typical Output Characteristics $T_j = 25^\circ\text{C}$

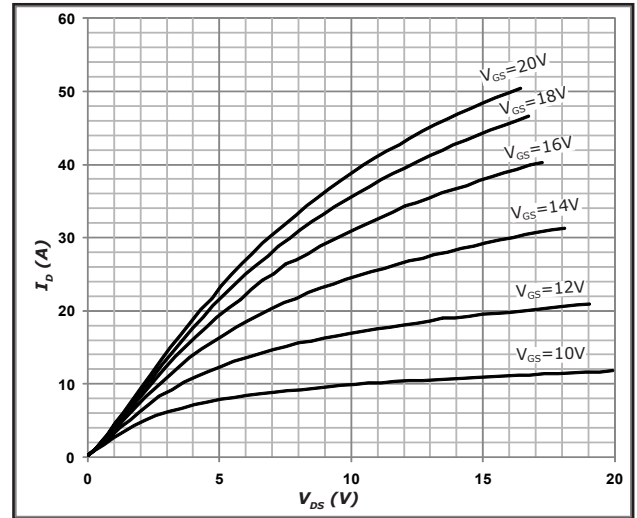


Fig 2. Typical Output Characteristics $T_j = 135^\circ\text{C}$

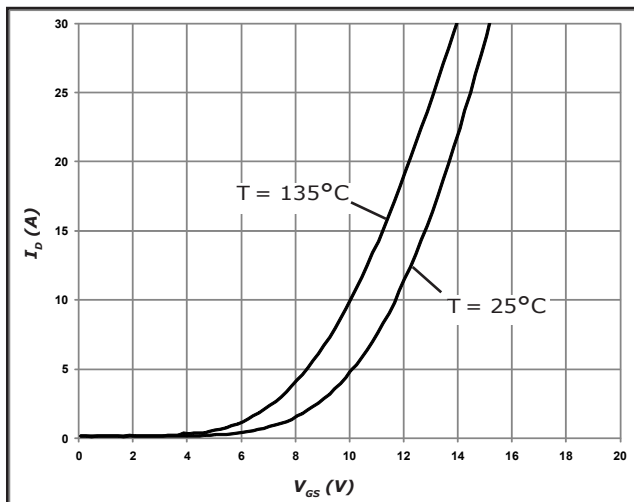


Figure 3. Typical Transfer Characteristics

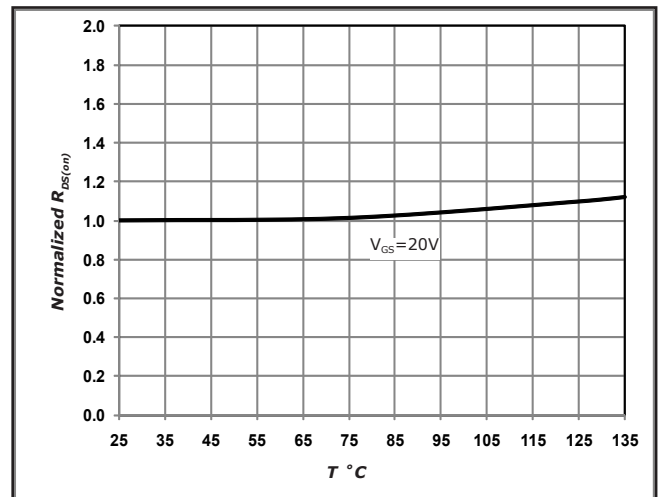


Fig 4. Normalized On-Resistance vs. Temperature

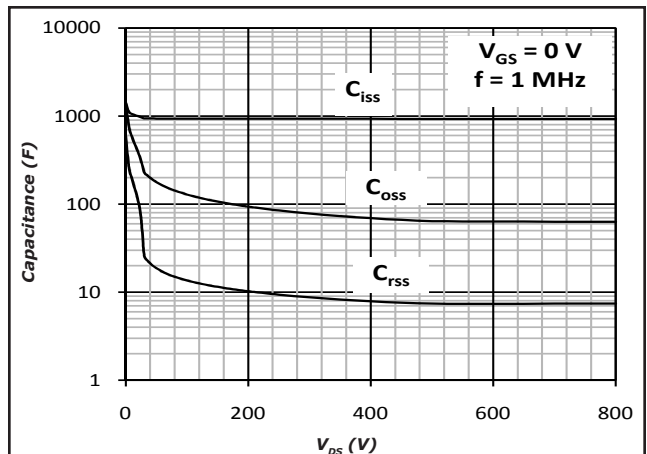
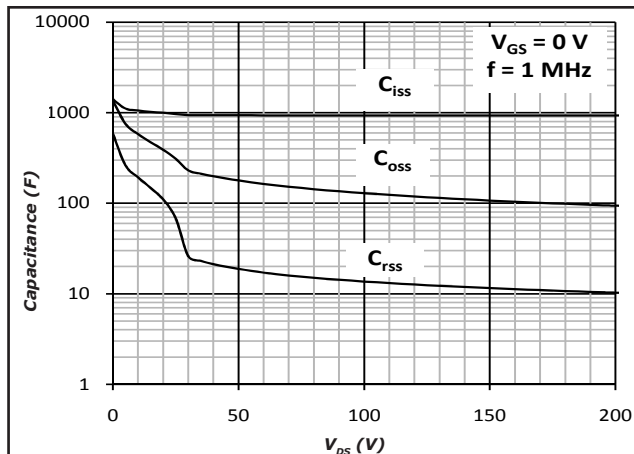


Fig 5A and 5B. Typical Capacitance vs. Drain – Source Voltage

Typical Performance

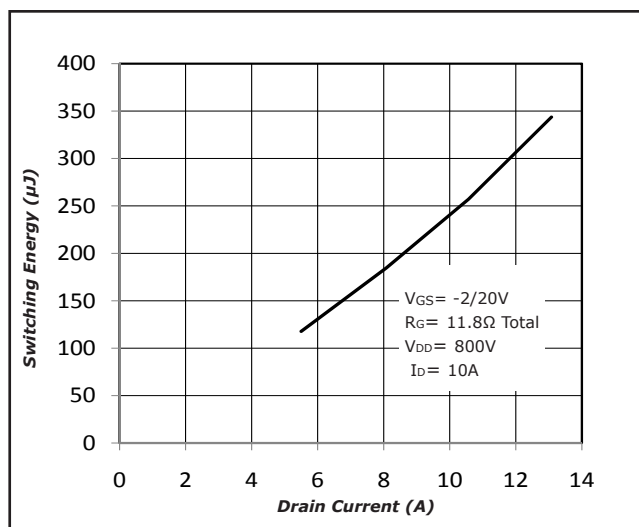


Fig 6. Inductive Switching Energy(Turn-on) vs ID

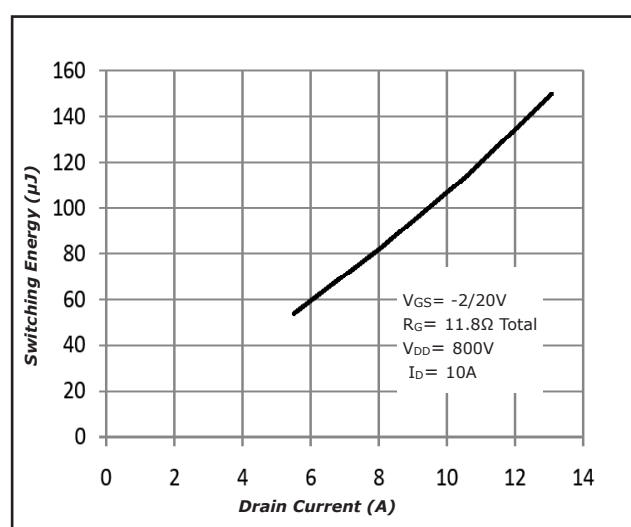


Fig 7. Inductive Switching Energy(Turn-off) vs ID

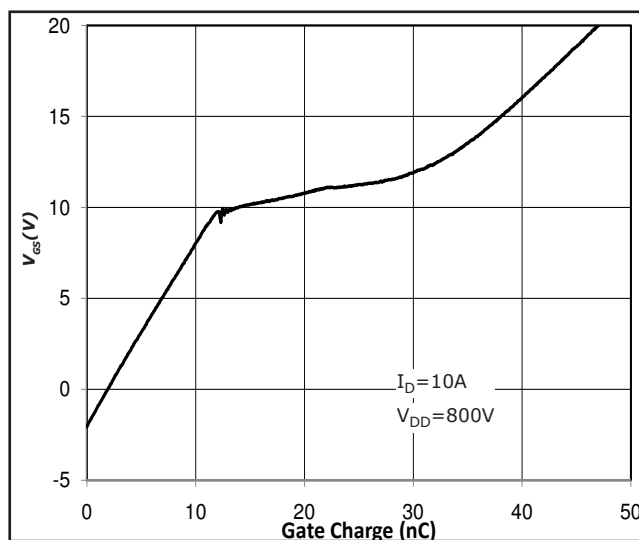


Fig 8. Typical Gate Charge Characteristics @ 25°C

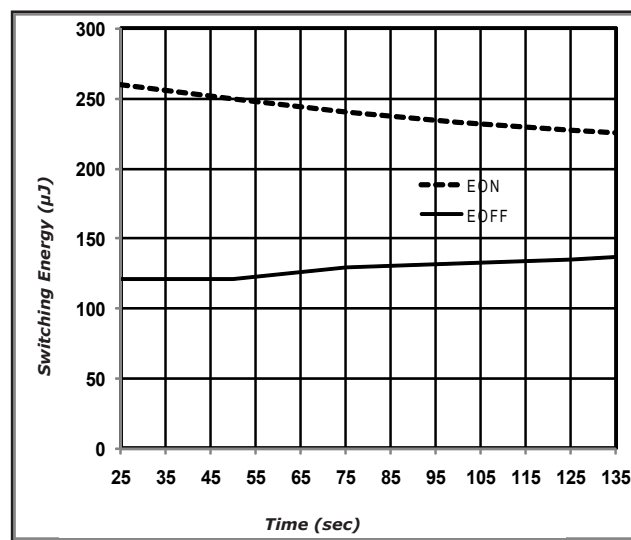


Fig 9. Inductive Switching Energy vs. Temp

Clamped Inductive Switch Testing Fixture

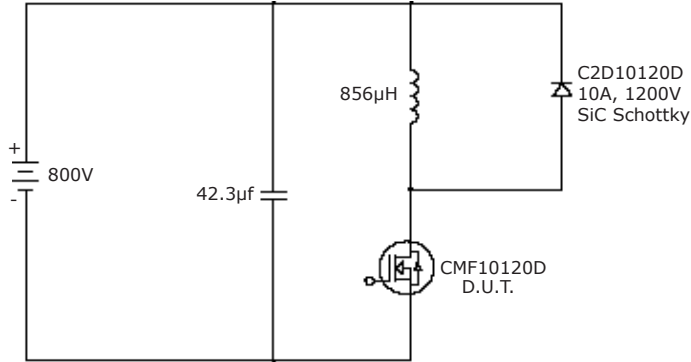


Fig 10. Switching Waveform Test Circuit

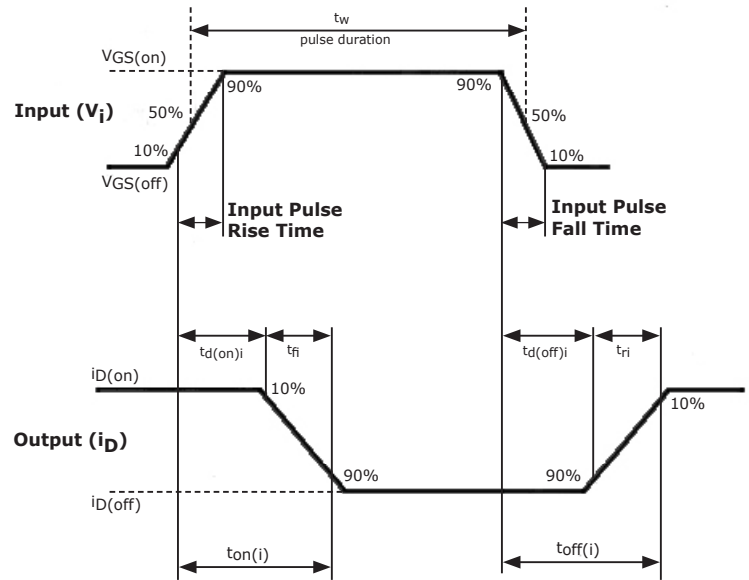


Fig 11. Switching Test Waveform Times

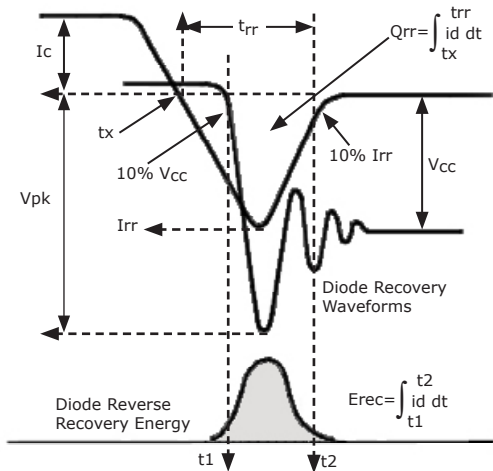


Fig 12. Body Diode Recovery Waveform

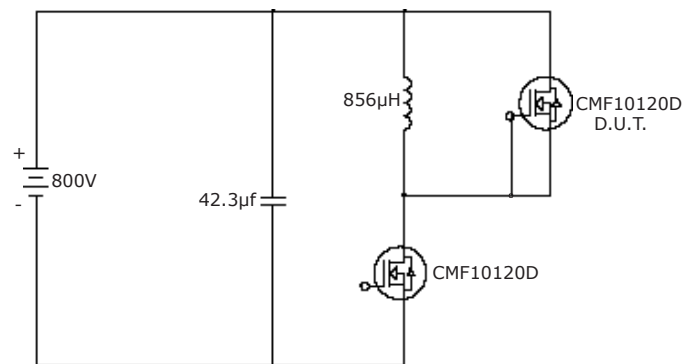


Fig 13. Body Diode Recovery Test

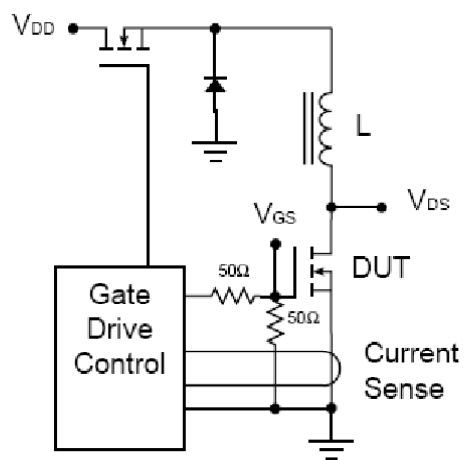


Fig 14. Avalanche Test Circuit

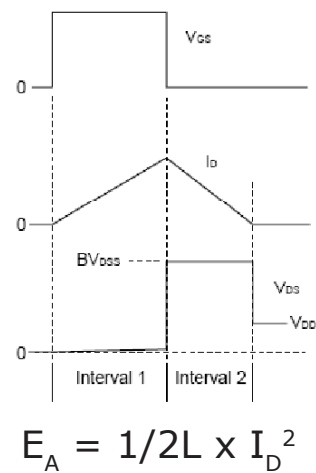
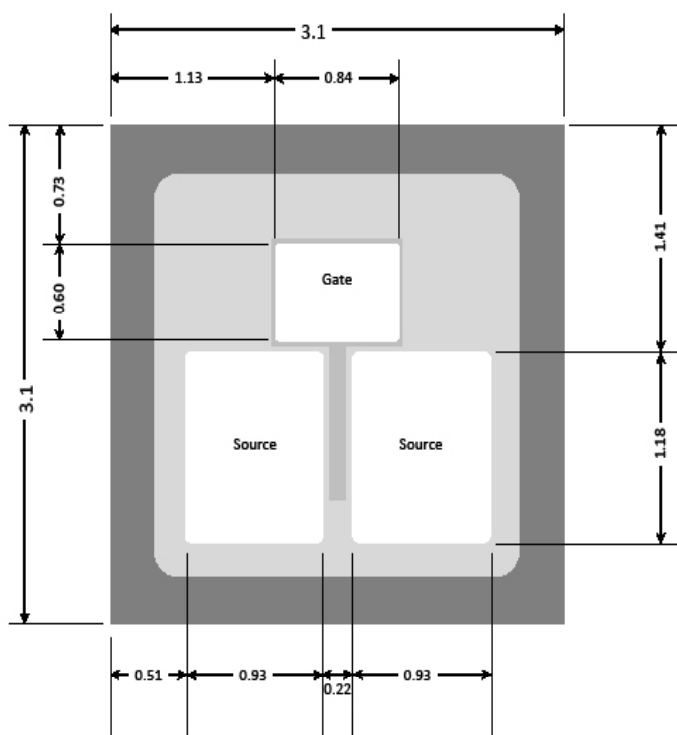


Fig 15. Theoretical Avalanche Waveform

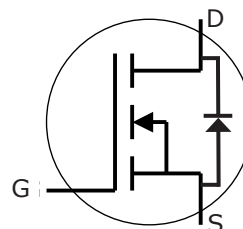
Mechanical Parameters

Parameter	Typ	Unit
Die Dimensions (L x W)	3.1 x 3.1	mm
Exposed Source Pad Metal Dimensions	0.93 x 1.18 (x 2)	mm
Gate Pad Dimensions	0.84 x 0.60	mm
Chip Thickness	390 ± 20	µm
Frontside (Source) metallization (Al)	4	µm
Frontside (Gate) metallization (Al)	4	µm
Backside (Drain) metallization (TiNi/Ag)	0.88 / 0.6	µm

Chip Dimensions



Part Number	Package
CPMF-1200-S160B	DIE



* The levels of environmentally sensitive, persistent biologically toxic (PBT), persistent organic pollutants (POP), or otherwise restricted materials in this product are below the maximum concentration values (also referred to as the threshold limits) permitted for such substances, or are used in an exempted application, in accordance with EU Directive 2002/95/EC on the restriction of the use of certain hazardous substances in electrical and electronic equipment (RoHS), as amended through April 21, 2006.

* The die-on-tape method of delivering these SiC die may be considered a means of temporary storage only. Due to an increase in adhesion over time, die stored for an extended period may affix too strongly to the tape. These die should be stored in a temperature-controlled nitrogen dry box soon after receipt. Cree will further recommend that all die be removed from tape to a waffle pack, to a similar storage medium, or used in production within 2 – 3 weeks of delivery to assure 100% release of all die without issues.

This product has not been designed or tested for use in, and is not intended for use in, applications implanted into the human body nor in applications in which failure of the product could lead to death, personal injury or property damage, including but not limited to equipment used in the operation of nuclear facilities, life-support machines, cardiac defibrillators or similar emergency medical equipment, aircraft navigation or communication or control systems, air traffic control systems, or weapons systems.

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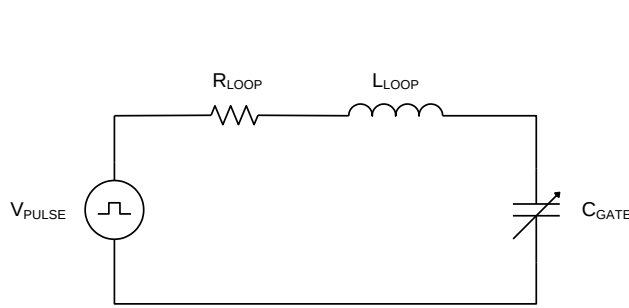
Cree, Inc.
4600 Silicon Drive
Durham, NC 27703
USA Tel: +1.919.313.5300
Fax: +1.919.313.5451
www.cree.com/power

Applications Information:

The Cree SiC DMOSFET has removed the upper voltage limit of silicon MOSFETs. However, there are some differences in characteristics when compared to what is usually expected with high voltage silicon MOSFETs. These differences need to be carefully addressed to get maximum benefit from the SiC DMOSFET. In general, although the SiC DMOSFET is a superior switch compared to its silicon counterparts, it should not be considered as a direct drop-in replacement in existing applications.

There are two key characteristics that need to be kept in mind when applying the SiC DMOSFETs; modest transconductance and no turn-off tail. The modest transconductance requires that V_{GS} needs to be 20V to optimize performance. This can be seen the Output and Transfer Characteristics shown in Figures 1-3. The modest transconductance also affects the transition where the device behaves as a voltage controlled resistance to where it behaves as a voltage controlled current source as a function of V_{DS} . The result is that the transition occurs over higher values of V_{DS} than is usually experienced with Si MOSFETs and IGBTs. This might affect the operation anti-desaturation circuits, especially if the circuit takes advantage of the device entering the constant current region at low values of forward voltage.

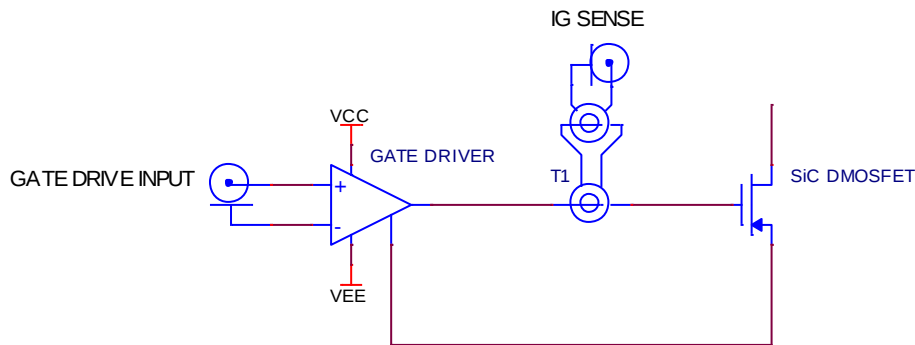
The modest transconductance needs to be carefully considered in the design of the gate drive circuit. The first obvious requirement is that the gate driver be capable of a 22V (or higher) swing. The recommended on state V_{GS} is +20V and the recommended off state V_{GS} is between -2V to -5V. Please carefully note that although the gate voltage swing is higher than typical silicon MOSFETs and IGBTs, the total gate charge of the SiC DMOSFET is considerably lower. In fact, the product of gate voltage swing and gate charge for the SiC DMOSFET is lower than comparable silicon devices. The gate voltage must have a fast dV/dt to achieve fast switching times which indicates that a very low impedance driver is necessary. Lastly, the fidelity of the gate drive pulse must be carefully controlled. The nominal threshold voltage is 2.3V and the device is not fully on ($dV_{DS}/dt \approx 0$) until the V_{GS} is above 16V. This is a noticeably wider range than what is typically experienced with silicon MOSFETs and IGBTs. The net result of this is that the SiC DMOSFET has a somewhat lower 'noise margin'. Any excessive ringing that is present on the gate drive signal could cause unintentional turn-on or partial turn-off of the device. The gate resistance should be carefully selected to insure that the gate drive pulse is adequately dampened. To first order, the gate circuit can be approximated as a



$$\zeta = \frac{R_{LOOP}}{2} \sqrt{\frac{C_{GATE}}{L_{LOOP}}} \geq 1$$

$$\therefore R_{LOOP} \geq 2 \sqrt{\frac{L_{LOOP}}{C_{GATE}}}$$

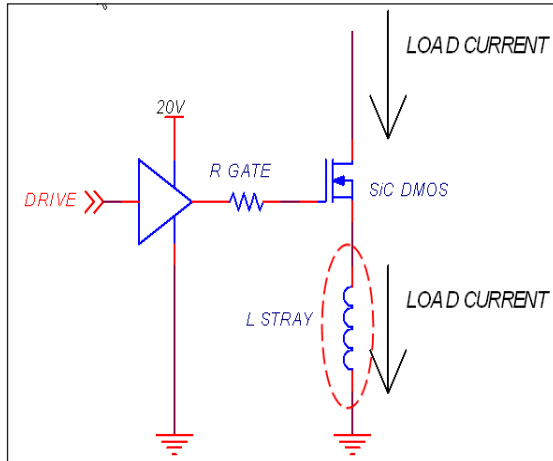
As shown, minimizing L_{LOOP} minimizes the value of R_{LOOP} needed for critical dampening. Minimizing L_{LOOP} also minimizes the rise/fall time. Therefore, it is strongly recommended that the gate drive be located as close to the SiC DMOSFET as possible to minimize L_{LOOP} . An external resistance of 6.8Ω was used to characterize this device. Lower values of external gate resistance can be used so long as the gate pulse fidelity is maintained. In the event that no external gate resistance is used, it is suggested that the gate current be checked to indirectly verify that there is no ringing present in the gate circuit. This can be accomplished with a very small current transformer. A recommended setup is a two-stage current transformer as shown below:



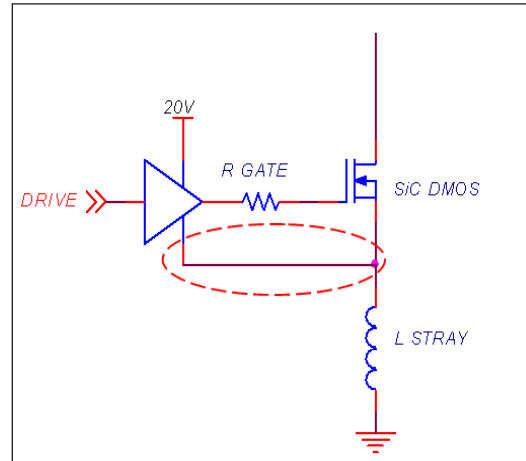
The two stage current transformer first stage consists of 10 turns of AWG 30 wire on a small high permeability core. A Ferroxcube 3E27 material is recommended. The second stage is a small wide bandwidth current transformer, such as the Tektronix CT-2. Lastly, a separate source return should be used for the gate drive as shown below:

Stray inductance on source lead causes load di/dt to be fed back into gate drive which causes the following:

- Switch di/dt is limited
- Could cause oscillation



Kelvin gate connection with separate source return is highly recommended



A significant benefit of the SiC DMOSFET is the elimination of the tail current observed in silicon IGBTs. However, it is very important to note that the current tail does provide a certain degree of parasitic dampening during turn-off. Additional ringing and overshoot is typically observed when silicon IGBTs is replaced with SiC DMOSFETs. The additional voltage overshoot can be high enough to destroy the device. Therefore, it is critical to manage the output interconnection parasitics (and snubbers) to keep the ringing and overshoot from becoming problematic.

ESD RATINGS

ESD Test	Total Devices Sampled	Resulting Classification
ESD-HBM	All Devices Passed 1000V	2 (>2000V)
ESD-MM	All Devices Passed 400V	C (>400V)
ESD-CDM	All Devices Passed 1000V	IV (>1000V)